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(71) Applicant (for all designated States except US): AEA
TECHNOLOGY PLC [GB/GB]; 329 Harwell, Didcot,
Oxfordshire OX11 0RA (GB).

(72) Inventors; and

(75) Inventors/Applicants (for US only): ANDREWS, Peter,
James [GB/GB]; 17 Donnington Place, Belmont Park,
Wantage, Oxfordshire OX12 9YE (GB). BEECH, Philip,
Michael [GB/GB]; 3 Darebt Place, Ladygrove, Didcot,
Oxfordshire OX11 7HQ (GB). MARTIN, Anthony,
Robert [GB/GB]; 17 Hamble Drive, Abingdon, Oxford-
shire OX14 3TF (GB). NG, Ka, Lok [GB/GB]; 8 Harwich
Close, Lower Barley, Reading, Berkshire RG6 3UD (GB).
SHAWCROSS, James, Timothy [GB/GB]; 27 Ticknell
Piece Road, Charlbury, Oxfordshire OX7 3TN (GB).

WEEKS, David, Michael [GB/GB]; 60 Blandy Avenue,
Southmoor, Abingdon, Oxfordshire OX13 5DB (GB).
REYNOLDS, David, Allen [GB/GB]; 6 Sherwood Road,
Didcot, Oxfordshire OX11 0BU (GB).

(74) Agents: LOFTING, Marcus, John et al.; AEA Technol-
ogy plc, Patents Dept., 329 Harwell Didcot, Oxfordshire
OX11 0RA (GB).

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(54) Title: DIELECTRIC BARRIER GAS REACTORS WITH NON-AXIAL FLOW

(57) Abstract: A dielectric barrier reactor for the plasma-assisted processing of a gaseous medium in which the gaseous medium is constrained to pass between the co-axial electrodes with axial, radial and circumferential gas flow components combinations of which result in the gas flow being at least partially helical and/or spiral.